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March 1, 1993

Ms. Rebecca Frey
Remedial Response Branch (HSRL-6J)
U.S. EPA, Region 5
77 West Jackson Boulevard
Chicago, IL 60604

      Re: Comments of Kerr-McGee Chemical Corporation
          on the Focused Risk Assessment for the West
          Chicago Vicinity Properties and the
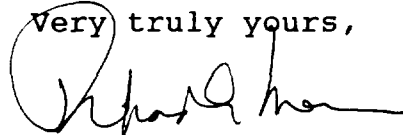   <u>Associated Fact Sheet</u>

Dear Ms. Frey:

      On February 25, 1993, Kerr-McGee Chemical
Corporation ("Kerr-McGee") submitted comments on the <u>Focused
Risk Assessment For West Chicago Vicinity Properties</u> (Jan.
1993). As you know, Kerr-McGee had only a few days within
which to prepare and file the comments. As a result, we have
discovered that our comments include one minor inaccuracy.

      On page 8 of the Kerr-McGee comments we state that
"Kerr-McGee has <u>never</u> encountered substantial volumes of
undiluted tailings in the residential areas." As it happens,
there were two residential sites -- out of the 2726 that were
surveyed and, as necessary, remediated -- at which extensive,
undiluted tailings were encountered. These sites were clearly
unusual and cannot be expected to recur. Although the basic
point of our comments is valid -- namely, that EPA was
incorrect in its characterization of the extent of tailings
contamination at the residential sites -- I am writing to
inform you that the assertion on page 8 of our comments was
overstated.

Ms. Rebecca Frey
March 1, 1993
Page 2

I apologize for this error. If there are any
aspects of our comments on which you seek further information,
please contact me.

Very truly yours,

Richard A. Meserve

cc: Mr. Valdus V. Adamkus
       David A. Ullrich
       Mark Radell, Esq.